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thin solid films

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Contents

Letter

Epitaxial aluminum nitride films on sapphire formed by pulsed laser deposition
S. Six, J.W. Gerlach, B. Rauschenbach 1

Synthesis and Characterization

Synthetic process of the sol–gel derived $Pb(Zr_{0.53}Ti_{0.47})O_3$ films using poly vinyl butyral binder
Y. Takahashi 5

Bias sputtered Ta modified diffusion barrier in Cu/Ta(V_b)/Si(111) structures
A.Z. Moshfegh, O. Akhavan 10

Sputter deposition of NiTi thin film shape memory alloy using a heated target
K.K. Ho, G.P. Carman. 18

Preparation and characterization of $Bi_2Ti_2O_7$ thin films by chemical solution deposition technique
X.M. Wu, Sh.W. Wang, H. Wang, Z. Wang, S.X. Shang, M. Wang 30

Reactive magnetron sputtering of indium tin oxide films on acrylics – morphology and bonding state
J.-L. Huang, Y.-T. Jah, B.-S. Yau, C.-Y. Chen, H.-H. Lu 33

Characterization of ultrasonic spray pyrolyzed tungsten oxide thin films
P.S. Patil, P.R. Patil, E.A. Ennaoui 38

The microstructure and mechanical properties of TaN/TiN and TaWN/TiN superlattice films
X. Junhua, L. Geyang, G. Mingyuan 45

Deposition and photoluminescence of sol–gel derived Tb^{3+}:Zn_2SiO_4 films on SiO_2/Si
H.X. Zhang, C.H. Kam, Y. Zhou, X.Q. Han, S. Buddhudu, Y.L. Lam, C.Y. Chan 50

In-situ TEM observations of abnormal grain growth, coarsening, and substrate de-wetting in nanocrystalline Ag thin films
R. Dannenberg, E.A. Stach, J.R. Groza, B.J. Dresser 54

Field-emission characteristics of chemical vapor deposition-diamond films
X.L. Peng 63

Phase development in pulsed laser deposited $Pb[Yb_{1/2}Nb_{1/2}]O_3$-$PbTiO_3$ thin films
V. Bornand, S. Trolier-Mckinstry 70

Dielectric properties of plasma-polymerized diphenyl thin films
F.-U.-Z. Chowdhury, A.H. Bhuiyan. 78

Submonolayer and single crystal film from ligand-stabilized silver nanoparticles
H.X. Li, M.Z. Lin, J.G. Hou 85

Chemical bath deposition of different phases of copper selenide thin films by controlling bath parameters
M. Lakshmi, K. Bindu, S. Bini, K.P. Vijayakumar, C. Sudha Kartha, T. Abe, Y. Kashiwaba 89

Microstructure-related resistivity change after chemical–mechanical polish of Al and W thin films
W.-T. Tseng, Y.-L. Wang, J. Niu 96

Deposition of tellurium films by decomposition of electrochemically-generated H_2Te: application to radiative cooling devices
T. Engelhard, E.D. Jones, I. Viney, Y. Mastai, G. Hodes 101

Internal stress and adhesion of amorphous Ni–Cu–P alloy on aluminum
C.-J. Chen, K.-L. Lin 106

Tungsten chemical vapor deposition using tungsten hexacarbonyl: microstructure of as-deposited and annealed films
K.K. Lai, H.H. Lamb 114

Use of artificial neural networks to predict thickness and optical constants of thin films from reflectance data
M.F. Tabet, W.A. McGahan 122

Structural studies and influence of the structure on the electrical and optical properties of microcrystalline silicon thin films produced by RF sputtering
M.F. Cerqueira, J.A. Ferreira, G.J. Adriaenssens 128

Preparation and properties of TiN and AlN films from alkoxide solution by thermal plasma CVD method
S. Shimada, M. Yoshimatsu, H. Nagai, M. Suzuki, H. Komaki 137

Preparation of $(Ti_{1-x}Al_x)N$ films from mixed alkoxide solutions by plasma CVD
S. Shimada, M. Yoshimatsu 146

Deposition and optical studies of silicon carbide nitride thin films
K.B. Sundaram, J. Alizadeh 151

Characterization of indium tin oxide film and practical ITO film by electron microscopy
T. Nakao, T. Nakada, Y. Nakayama, K. Miyatani, Y. Kimura, Y. Saito, C. Kaito 155

Characterization of titanium dioxide atomic layer growth from titanium ethoxide and water
J. Aarik, A. Aidla, V. Sammelselg, T. Uustare, M. Ritala, M. Leskelä 163

Structural and optical properties of yttria-stabilized-zirconia films grown by MOCVD
G. Garcia, A. Figueras, R.I. Merino, V.M. Orera, J. Llibre 173

Surfaces, Interfaces and Colloidal Behaviour

Cluster diffusion and surface morphological transitions on Pt(111) via reptation and concerted motion
V. Chirita, E.P. Münger, J.E. Greene, J.-E. Sundgren 179

Face centred cubic cobalt ultrathin-layers in Au/Co(111) multilayers: a study by electron diffraction and by HREM
S. Jomni, N. Mliki, R. Belhi, K. Abdelmoula, M. Ayadi, G. Nihoul 186

Density functional study of silane adsorption onto Si(100) surface
J.S. Lin, Y.T. Kuo 192

In situ Fourier transform P-polarized infrared reflection absorption spectroscopic investigation of an interface properties of SiO_2/Si(100) deposited using electron cyclotron resonance microwave plasma at room temperature
Y. Jia, Y. Liang, Y. Liu, Y. Liu, D. Shen 199

Metallurgical, Protective and Hard Layers

Chemical vapour deposition of molybdenum carbides: aspects of phase stability
J. Lu, H. Hugosson, O. Eriksson, L. Nordström, U. Jansson 203

Plasma spraying of stainless-steel particles coated with an alumina shell
H. Ageorges, P. Fauchais 213

Supertough wear-resistant coatings with 'chameleon' surface adaptation
A.A. Voevodin, J.S. Zabinski 223

Mechanics and Nanomechanics of Thin Layers

A unified theoretical model for tensile and compressive residual film stress
G. Knuyt, W. Lauwerens, L.M. Stals 232

Electric force microscopy study of the surface electrostatic property of rubbed polyimide alignment layers
X. Liang, J. Liu, L. Han, H. Tang, S.-Y. Xu 238

Electronics, Optics and Opto-electronics

Optical properties of Er^{3+}-doped SiO_2-GeO_2-Al_2O_3 planar waveguide fabricated by sol–gel processes
Q. Xiang, Y. Zhou, B.S. Ooi, Y.L. Lam, Y.C. Chan, C.H. Kam 243

Fabrication of a new photoelectric conversion system by using a self-assembling technique
J. Zhai, T.-X. Wei, C.-H. Huang 248

Dark and photoelectric conversion properties of p-MgPc/n-Si (Organic/Inorganic) heterojunction cells
S. Riad 253

Crystal structure of GeTe and $Ge_2Sb_2Te_5$ meta-stable phase
T. Nonaka, G. Ohbayashi, Y. Toriumi, Y. Mori, H. Hashimoto 258

Improvement of luminescence efficiency and photostability in polymer thin films
S.M. Lipson, D.F. O'Brien, H.J. Byrne, A.P. Davey, W.J. Blau 262

Titanium–aluminum–nitride coatings for satellite temperature control
M. Brogren, G.L. Harding, R. Karmhag, C.G. Ribbing, G.A. Niklasson, L. Stenmark 268

Langmuir–Blodgett: Biological and Related Films

Surface characterization of the monolayer and Langmuir–Blodgett films of tetra-tert-butyl-copper phthalocyanine
Y.-L. Lee, Y.-C. Chen, C.-H. Chang, Y.-M. Yang, J.-R. Maa 278

Vacuum-deposited films of mesogen of 4-*n*-pentyl-4″-cyano-*p*-terphenyl: their electronic spectra and molecular aggregate structures
T. Sumiyoshi, I. Takahashi, Y. Tsuboi, H. Miyasaka, A. Itaya, T. Asahi, H. Masuhara 285

An air-stable biomimetic Langmuir–Blodgett bilayer
S. Ryley, A.T. Chyla, I.R. Peterson 294

Thin Film Devices, Sensors and Actuators

Study of in situ $CdCl_2$ treatment on CSS deposited CdTe films and CdS/CdTe solar cells
P.D. Paulson, V. Dutta 299

High temperature cracking of tungsten polycide films on quartz substrate
J. Lee, S.-H. Oh, J. Lee, E. Lee, I. Lim, W.-K. Park, G. Kim 307

Condensed Matter Film Behaviour

Propagation loss and birefringence properties around 1.55 μm of polymeric optical waveguides fabricated with cross-linked silicone
S. Toyoda, N. Ooba, M. Hikita, T. Kurihara, S. Imamura 311

Stress development in FeAl8 thin films during heat treatment
W. Zeiger, W. Brückner, J. Schumann, W. Pitschke, H. Worch 315

Author Index of Volume 370 321

Subject Index of Volume 370 323

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